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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Akira MATSUDA et al.**

Group Art Unit: 1775

Serial Number: 10/719,020

Examiner: **Robert R. Koehler**

Filed: **November 24, 2003**

Confirmation Number: 9168

For: **PLATING BATH FOR FORMING THIN RESISTANCE LAYER,
METHOD OF FORMATION OF RESISTANCE LAYER,
CONDUCTIVE BASE WITH RESISTANCE LAYER, AND CIRCUIT
BOARD MATERIAL WITH RESISTANCE LAYER**

Attorney Docket Number: **032130**

Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

March 10, 2006

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated September 14, 2005 for three months from December 14, 2005 to March 14, 2006.

Attached please find a check in the amount of \$1,020.00 for the cost of the extension. If any additional fees are due in connection with this paper, please charge our Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

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